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APPLICATION NO.	FI	LING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO	CONFIRMATION NO.	
10/797,867	03/10/2004		Po-Cheng Chen	250122-1350	2229	
24504	7590	08/16/2006		EXAMINER		
		N, HORSTEMEY	LEWIS	LEWIS, MONICA		
100 GALLER	RIA PARI	KWAY, NW				
STE 1750				ART UNIT	PAPER NUMBER	
ATLANTA,	GA 303	39-5948	2822	·		

DATE MAILED: 08/16/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	_				
Office Author Commons	10/797,867	CHEN ET AL.					
Office Action Summary	Examiner	Art Unit					
	Monica Lewis	2822					
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address					
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be time rill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE!	L. ely filed the mailing date of this communication. O (35 U.S.C. § 133).					
Status							
1) Responsive to communication(s) filed on 27 M	av 2006						
	action is non-final.						
· -							
,	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims	•						
4)⊠ Claim(s) 12-22 is/are pending in the application	,						
	4a) Of the above claim(s) <u>14-21</u> is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.							
6) Claim(s) 12,13 and 22 is/are rejected.							
7) Claim(s) is/are objected to.							
8) Claim(s) are subject to restriction and/or	r election requirement						
o) Claim(s) are subject to restriction and/or	election requirement.						
Application Papers							
9) ☐ The specification is objected to by the Examine	r.						
10)⊠ The drawing(s) filed on 10 March 2004 is/are: a	a)⊠ accepted or b)⊡ objected to	by the Examiner.					
Applicant may not request that any objection to the	drawing(s) be held in abeyance. See	: 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the correct	ion is required if the drawing(s) is obj	ected to. See 37 CFR 1.121(d).					
11)☐ The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PTO-152.					
Priority under 35 U.S.C. § 119							
 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the prior application from the International Bureau * See the attached detailed Office action for a list 	s have been received. s have been received in Application ity documents have been receive (PCT Rule 17.2(a)).	on No ed in this National Stage					
Attachment(s) 1) X Notice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)					
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail Da	te					
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	5) Notice of Informal Professional Profession Other:	atent Application (PTO-152)					

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DETAILED ACTION

1. This office action is in response to the response filed May 27, 2006.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 3. Claims 12 and 13 are rejected under 35 U.S.C. 102(b) as being anticipated by Takagi et al. (U.S. Patent No. 6,376,986).

In regards to claim 12, Takagi et al. ("Takagi") discloses the following:

- a) a front substrate (11) (For Example: See Figure 14);
- a) a rear substrate (21) (For Example: See Figure 14); and
- b) at least one set of alignment marks is installed on the front and rear substrates, the set of alignment marks comprise a first and second pattern installed on the predetermined assembling position of the first and second substrate respectively, the second pattern comprises at least a hexagonal honeycomb pattern (29) formed with rib barriers, a line segment of the first pattern (Xq and Yq) is parallel to at least one side of the hexagonal honeycomb pattern with a predetermined distance there between, and the first and second patterns are used to align between the front and rear substrates, when assembling a PDP (For Example: See Figure 14).

In regards to claim 13, Takagi discloses the following:

a) the first pattern comprises a plurality of parallel line segments (For Example: See Figure 14).

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4. Claims 12 and 13 are rejected under 35 U.S.C. 102(b) as being anticipated by Kuni et al. (Japanese Publication No. 2000-011894).

In regards to claim 12, Kuni et al. ("Kuni") discloses the following:

- a) a front substrate (41) (For Example: See Figure 1);
- a) a rear substrate (51) (For Example: See Figure 1); and
- b) at least one set of alignment marks is installed on the front and rear substrates, the set of alignment marks comprise a first and second pattern installed on the predetermined assembling position of the first and second substrate respectively, the second pattern comprises at least a hexagonal honeycomb pattern formed with rib barriers, a line segment of the first pattern (43) is parallel to at least one side of the hexagonal honeycomb pattern with a predetermined distance there between, and the first and second patterns are used to align between the front and rear substrates, when assembling a PDP (For Example: See Figure 1).

In regards to claim 13, Kuni discloses the following:

a) the first pattern comprises a plurality of parallel line segments (For Example: See Figure 14).

Claim Rejections - 35 USC § 103

- 5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 6. Claim 22 is rejected under 35 U.S.C. 103(a) as being unpatentable over Takagi et al.
- (U.S. Patent No. 6,376,986) in view of Boo et al. (Korean Publication No. 2002019353).

In regards to claim 22, Takagi fails to disclose the following:

a) the first pattern installed on the front substrate comprises non-transparent bus electrode material or black matrix material.

However, Boo et al. ("Boo") discloses a semiconductor device that has a first pattern installed on the front substrate (10) comprises non-transparent bus electrode material (13) or black matrix material (For Example: See Abstract). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor of Takagi to include a first pattern installed on the front substrate that comprises a non-transparent bus electrode material or black matrix material as disclosed in Boo because it aids in providing a discharge sustain function (For Example: See Abstract).

Additionally, since Takagi and Boo are both from the same field of endeavor, the purpose disclosed by Boo would have been recognized in the pertinent art of Takagi.

7. Claim 22 is rejected under 35 U.S.C. 103(a) as being unpatentable over Kuni et al. (Japanese Publication No. 2000-011894) in view of Boo et al. (Korean Publication No. 2002019353).

In regards to claim 22, Takagi fails to disclose the following:

a) the first pattern installed on the front substrate comprises non-transparent bus electrode material or black matrix material.

However, Kuni discloses a semiconductor device that has a first pattern installed on the front substrate (10) comprises non-transparent bus electrode material (13) or black matrix material (For Example: See Abstract). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor of Kuni to include a first pattern installed on the front substrate that comprises a non-transparent bus electrode material or black matrix material as disclosed in Boo because it aids in providing a discharge sustain function (For Example: See Abstract).

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Additionally, since Kuni and Boo are both from the same field of endeavor, the purpose disclosed by Boo would have been recognized in the pertinent art of Kuni.

Conclusion

8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Monica Lewis whose telephone number is 571-272-1838.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Zandra Smith can be reached on 571-272-2429. The fax phone number for the organization where this application or proceeding is assigned is 571-272-8300 for regular and after final communications.

ML

August 2, 2006

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